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INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

ATTY DOCKET NO.
106200.01APPLICATION NO.
Rule 53(b) Continuing
Application of U.S.
Application No. 09/571,864
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APPLICANTS

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FILING DATE

February 26, 2002

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS
W	4,349,583	09/1982	KULYNYCH et al.	427	53.1
W	4,217,183	08/1980	MELCHER et al.	204	15

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

W	Gutfield et al., <u>Electrochemical microfabrication by laser-enhanced photothermal processes</u> , IBM J. Res. Develop., Vol. 42, No. 5, 1998, pp. 639-652. <u>no month</u>
W	Chichkov et al., <u>Femtosecond, picosecond and nanosecond laser ablation of solids</u> , Applied Physics A, 63, 1996, pp. 109-115. <u>no month</u>
W	Obara et al., <u>Laser Engineering Optics</u> , Kyoritsu Shuppan, 1998, pp. 130-133. <u>no month</u>
W	GUTFELD et al., "Electrochemical Microfabrication by Laser-Enhanced Photothermal Processes," J. Res. Develop., Vol. 42, No. 5, pp. 639-652, September 1998.

EXAMINER

Sama Wang

DATE CONSIDERED

1/22/04

Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.